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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/025,442	12/18/2001	Kevin M. Mukai	005042	6598
32588	7590 03/24/2004		EXAM	INER
	ATERIALS, INC.	ALANKO, ANITA KAREN		
2881 SCOTT BLVD. M/S 2061 SANTA CLARA, CA 95050			ART UNIT	PAPER NUMBER
SANTA CLA	rai, or soot		1765	

DATE MAILED: 03/24/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
	10/025,442	MUKAI ET AL.			
Office Action Summary	Examiner	Art Unit			
	Anita K Alanko	1765			
The MAILING DATE of this communication a	ppears on the cover sheet w	vith the correspondence address			
Period for Reply	IVIC CET TO EVDIDE 21	MONTH(S) FROM			
A SHORTENED STATUTORY PERIOD FOR REP THE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a re - If NO period for reply is specified above, the maximum statutory perio - Failure to reply within the set or extended period for reply will, by statu Any reply received by the Office later than three months after the mai earned patent term adjustment. See 37 CFR 1.704(b).	l. 1.136(a). In no event, however, may a eply within the statutory minimum of the d will apply and will expire SIX (6) MC	n reply be timely filed irty (30) days will be considered timely. INTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 11.	/10/03 RCE & IDS.				
	nis action is non-final.				
3) Since this application is in condition for allow		atters, prosecution as to the merits is			
closed in accordance with the practice unde	r <i>Ex parte Quayle</i> , 1935 C	D. 11, 453 O.G. 213.			
Disposition of Claims					
4) ☐ Claim(s) <u>1-6</u> is/are pending in the application	1.	•			
4a) Of the above claim(s) is/are withd					
5) Claim(s) is/are allowed.					
6)⊠ Claim(s) <u>1-4 and 6</u> is/are rejected.					
7)⊠ Claim(s) <u>5</u> is/are objected to.					
8) Claim(s) are subject to restriction and	d/or election requirement.				
Application Papers					
	iner				
9) The specification is objected to by the Examiner.10) The drawing(s) filed on is/are: a) accepted or b) objected to by the Examiner.					
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
Replacement drawing sheet(s) including the corr	ection is required if the drawi	ng(s) is objected to. See 37 CFR 1.121(d).			
11)☐ The oath or declaration is objected to by the	Examiner. Note the attach	ned Office Action or form PTO-152.			
Priority under 35 U.S.C. § 119	ion neigritu under 25 11 C C	& 119(a)-(d) or (f)			
12) Acknowledgment is made of a claim for fore	ign priority under 35 U.S.C	. 3 113(a)-(u) or (i).			
a) All b) Some * c) None of:	ante hava haen received				
1. Certified copies of the priority docume2. Certified copies of the priority docume		Application No.			
	riority documents have be	en received in this National Stage			
3. Copies of the certified copies of the papplication from the International Bur					
* See the attached detailed Office action for a		ot received.			
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Attachment(s)	Δ\ □ Intervie	w Summary (PTO-413)			
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper N	lo(s)/Mail Date			
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/	· =	of Informal Patent Application (PTO-152)			
Paper No(s)/Mail Date <u>11/10/03</u> .	6) Other:				

Application/Control Number: 10/025,442

Art Unit: 1765

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after allowance or after an Office action under *Ex Parte Quayle*, 25 USPQ 74, 453 O.G. 213 (Comm'r Pat. 1935). Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, prosecution in this application has been reopened pursuant to 37 CFR 1.114. Applicant's submission filed on 11/10/03 has been entered.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1, 3 and 5 are rejected under 35 U.S.C. 102(b) as being anticipated by Ikeda (US 5,593,741).

Ikeda discloses a method comprising:

in a wafer processing environment, introducing a liquid via a carrier gas 32,36 (col.4, lines 56-63); and

separate from the liquid, introducing a first gas 42,44,46 comprising ozone and a legacy amount of oxygen (col.4, line 64-col.5, line 2) and a second gas 48,50 comprising an effective amount of oxygen to modify a process operation (col.5, lines 2-5).

Art Unit: 1765

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-3 and 5 are rejected under 35 U.S.C. 103(a) as being unpatentable over Park et al (US 5,891,810) in view of Ikeda (US 5,593,741).

Park discloses a method comprising:

in a wafer processing environment, introducing a silicon source 3b (col.1, lines 53-54); and

separate from the liquid, introducing a first gas 12 comprising ozone and a legacy amount of oxygen (col.3, lines 15-16) and a second gas 13 comprising an effective amount of oxygen to modify a process operation (col.3, lines 28-29).

Park does not disclose that the silicon source is by introducing a liquid via a carrier gas. Ikeda teaches a useful method for introducing the silicon source comprising introducing a liquid via a carrier gas 32,36 (col.4, lines 56-63). It would have been obvious to one with ordinary skill in the art to introduce the silicon source by introducing a liquid via a carrier gas in the method of Park because Ikeda teaches that this is a useful technique for doing so.

As to claim 2, Park discloses to combine the gases (Fig.3).

As to claim 3, Park discloses to control the amount of oxygen in the first gas (col.3, lines 15-35).

Application/Control Number: 10/025,442

Art Unit: 1765

As to claim 5, Park teaches that the second gas modifies the film formation (see abstract, modification by changing the concentration of ozone in each layer).

Allowable Subject Matter

Claim 4 is objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

The following is a statement of reasons for the indication of allowable subject matter: the prior art does not teach or suggest an etching environment wherein the effective amount of the second gas modifies the etch rate of an etch operation, as in the context of claim 4.

The closest prior art, Ikeda, discloses film formation not etching, and there is no motivation to etch in the method of Ikeda.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Anita K Alanko whose telephone number is 571-272-1458. The examiner can normally be reached on Mon, Tues & Fri: 8:30 am-5 pm; Wed&Thurs:10 am-2 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 10/025,442

Art Unit: 1765

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

duita K. Alanko

Anita K Alanko Primary Examiner Art Unit 1765